

<b>Notice of References Cited</b>	Application/Control No. 10/632,825	Applicant(s)/Patent Under Reexamination LEE ET AL.	
	Examiner Evan Pert	Art Unit 2826	Page 1 of 1

**U.S. PATENT DOCUMENTS**

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
	A	US-6,753,618	06-2004	Basceri et al.	257/296
	B	US-2003/0232511	12-2003	Metzner et al.	438/785
	C	US-			
	D	US-			
	E	US-			
	F	US-			
	G	US-			
	H	US-			
	I	US-			
	J	US-			
	K	US-			
	L	US-			
	M	US-			

**FOREIGN PATENT DOCUMENTS**

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Country	Name	Classification
	N					
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	P					
	Q					
	R					
	S					
	T					

**NON-PATENT DOCUMENTS**

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
	U	Document entitled "Technology Backgrounder: Atomic Layer Deposition" from "IC Knowledge LLC" downloaded from <a href="http://www.icknowledge.com/misc_technology/Atomic%20Layer%20Deposition%20Briefing.pdf">http://www.icknowledge.com/misc_technology/Atomic%20Layer%20Deposition%20Briefing.pdf</a> , 7 pages, 2004.
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\*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)  
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